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Application No.	Applicant(s)	7110
10/623,581	KOBORI ET AL.	
Examiner	Art Unit	
Stanetta D. Isaac	2812	··
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6. ☐ Interview Summa Paper No./Mail I 7. ☑ Examiner's Amer 8. ☑ Examiner's State 9. ☐ Other	ary (PTO-413), Date ndment/Comment ment of Reasons for Allowa Tyme A. Juney LYNNE A. GURLEY	ance
	OR REMAINS) CLOSED in this or other appropriate communication. This application is subjected and MPEP 1308. MOS. er 35 U.S.C. § 119(a)-(d) or (f). Or other received. Deen received. Deen received in Application Note that application. ed. Note the attached EXAMIN reason(s) why the oath or decibe submitted. In's Patent Drawing Review (PTAMENTAL AMENTAL	Examiner Stanetta D. Isaac Stanetta D. Isaac To son the cover sheet with the correspondence address on REMAINS) CLOSED in this application. If not included in other appropriate communication will be mailed in due could be subjected to withdrawal from issue and MPEP 1308. Mos. This application is subject to withdrawal from issue and MPEP 1308. Mos. The are received. The are received in Application No. Imments have been received in this national stage application. This application. This application. The are received in Application No. Imments have been received in this national stage application. The submitted in this application is deficient. The submitted. The are received in Application of the submitted. The submitted in the Office action of the submitted. The Area of the submitted in the Office action of the submitted in the Deposit of BIOLOGICAL MATERIAL. The DEPOSIT OF BIOLOGICAL MATERIAL.

U.S. Patent and Trademark Office PTOL-37 (Rev. 7-05) Application/Control Number: 10/623,581 Page 2

Art Unit: 2812

EXAMINER'S AMENDMENT/COMMENTS

An examiner's amendment/comments to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 12/05/05 has been entered.

Information Disclosure Statement

The information disclosure statement (IDS) submitted on 12/05/05 was filed after the mailing date of the Office Action on 7/13/05. The submission is in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure statement is being considered by the examiner.

REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

Art Unit: 2812

The closest prior art of record, Matsumoto US Patent 5,396,084 alone or in combination of, Matsumoto US Patent 5,396,084 in view of Iwanaga et al., US Patent 5,932,484 in further view of Shannon US Patent 5,466,617, fails to show the following steps of:

Pertaining to independent claims 16, 22 and 28, wherein the active matrix circuit includes "forming an interlayer insulating film comprising a silicon nitride layer and a silicon oxide layer over said semiconductor layer by plasma CVD, said silicon nitride layer and said silicon oxide layer formed over said gate electrode and said semiconductor layer; and forming a conductive (multi-layer film, for claim 22) layer comprising titanium and aluminum over said interlayer insulating film," that has both the silicon nitride layer and the silicon oxide layer.

Pertaining to independent claims 46, 51, and 56, wherein the active matrix circuit includes "forming a first interlayer insulating film comprising a silicon nitride layer and a silicon oxide layer over said semiconductor layer by plasma CVD, said silicon nitride layer and said silicon oxide layer formed over said gate electrode and said semiconductor layer; forming a conductive layer comprising a titanium and an aluminum over said first interlayer insulating film;" wherein the first interlayer insulating film has both the silicon nitride layer and the silicon oxide layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Application/Control Number: 10/623,581

Art Unit: 2812

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Stanetta D. Isaac whose telephone number is 571-272-1671. The examiner can normally be reached on Monday-Friday 9:30am -6:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Lebentritt can be reached on 571-272-1873. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Stanetta Isaac Patent Examiner December 6, 2005

LYNNE A. GURLEY
MINARY PATENT EXAMINER

Page 4

TC 2800, AU 2812